## Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application.

## **Listing of Claims:**

- 1. (currently amended) A template formed from a layered structure comprising: a substrate; and
- a single-phase polymer layer positioned on the substrate; [[,]]

wherein the polymer layer comprises a textured surface, the texturing being caused by induction of stress in the polymer layer after baking of the polymer layer at a temperature below the glass transition temperature of the polymer.

- 2. (original) A template according to claim 1, additionally comprising a semiconductor layer positioned on the polymer layer.
- 3. (previously presented) A template according to claim 1, wherein the single-phase polymer is selected from polymethylglutarimide (PMGI), polymethylmethacrylate (PMMA) and photoresist AZ5214E.
- 4. (previously presented) A template according to claim 2, wherein the semiconductor is germanium.

5. (previously presented) A template according to claim 1, wherein the substrate

comprises silicon.

6. (previously presented) A template according to claim 1, wherein the textured

surface comprises parallel grooves.

7. (previously presented) A template according to claim 1, wherein the thickness

of the single-phase polymer layer is 50-300 nm.

8. (previously presented) A template according to claim 2, wherein the thickness

of the semiconductor layer is approximately 10 nm.

Claims 9-26: Canceled

27. (new) A template according to claim 1, wherein the textured surface has

been stabilized by annealing after the induction of stress.

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